1 Custom high-voltage GaN-on-Si technology for power ICs.
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2 High-voltage monolithically integrated diode-clamped multilevel converter chip assembled in PCB embedding technology (AT&S -ECP®).
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Gallium nitride (GaN) is more than a high-performance semiconductor material: For the first time, monolithic integration enables a GaN technology which provides excellent device characteristics paired with higher functionality. At Fraunhofer IAF, we manufacture devices and circuits in our III-V process line. This 600 V-class GaN-on-Si technology offers new opportunities for various high-performance applications and customer specific solutions.

Features
- **High Functionality** due to monolithic integration (power circuits, gate driver, logic, sensors) and PCB-embedding assembly technology
- **High Frequencies** > 1 MHz due to AlGaN/GaN-heterojunction technology
- **High Compactness** by integrated GaN power circuits, and PCB embedding assembly technology

Applications
- **Mobility**: DC-DC converter, boardnet charger
- **Information Technology**: Point-of-load (PoL) converters for data centers, and cloud servers
- **Industrie 4.0**: compact and robust power electronics for industrial facilities
- **Consumer Electronics**: battery charger, home entertainment